

Gp 1246

TSMC-00-023C



March 12, 2003

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To: Commissioner of Patents and Trademarks  
Washington, D.C. 20231

Fr: George O. Saile, Reg. No. 19,572  
28 Davis Avenue  
Poughkeepsie, N.Y. 12603

Subject:

Serial No. 09/629,213 07/31/00

Chie-Chi Chen et al.

PHOTORESIST STRIPPER USING  
NITROGEN BUBBLER

Grp. Art Unit: 1746

#### SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Enclosed is Form PTO-1449, Information Disclosure Citation  
In An Application.

The following Patents and/or Publications are submitted to  
comply with the duty of disclosure under CFR 1.97-1.99 and  
37 CFR 1.56. Copies of each document is included herewith.

#### CERTIFICATE OF MAILING

I hereby certify that this correspondence is being  
deposited with the United States Postal Service as first class  
mail in an envelope addressed to: Commissioner of Patents and  
Trademarks, Washington, D.C. 20231, on March 13, 2003.

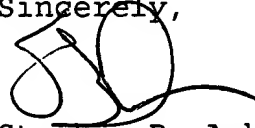
Stephen B. Ackerman, Reg.# 37761

Signature/Date

U.S. Patent 5,082,518 to Molinaro, "Sparger Plate for Ozone Gas Diffusion," discloses a gas diffusion system for evenly distributing injected gas in a bath including a diffusion sparger plate for spreading and distributing the gas.

U.S. Patent 5,776,296 to Matthews, "Apparatus for the Treatment of Semiconductor Wafers in a Fluid," discloses a process for removing organic materials from semiconductor wafers.

Sincerely,

A handwritten signature in black ink, appearing to be 'SBA', with a long horizontal flourish extending to the right.

Stephen B. Ackerman,  
Reg. No. 37761